


# Microposit MF-CD-26

<b>Product</b>	Microposit MF-CD-26 Developer
<b>Manufacturer</b>	Rohm And Haas Electronic Materials LLC
<b>Composition</b>	95.0–99.0% <a href="#">water</a> , 1.0–5.0% <a href="#">tetramethylammonium hydroxide</a> ; liquid
<b>Synonyms</b>	CD-26
<b>Typical Uses</b>	Developer for photolithography
<b>Hazards</b>	<p>300</p>  <p>Corrosive to metals <b>CATEGORY 1</b>, Specific target organ toxicity – single exposure <b>CATEGORY 1</b> (oral), Specific target organ toxicity – repeated exposure <b>CATEGORY 1</b> (dermal), Skin corrosion/irritation <b>CATEGORY 2</b>, Serious eye damage /eye irritation <b>CATEGORY 2A</b></p>
<b>Storage</b>	<a href="#">Cabinet 13</a> (bases cabinet in Wet Aisle 1); underneath litho wet decks
<b>Disposal</b>	Pour into wet deck (Litho Wet Deck 1/2, Wet Deck 1A/1B/2A) and rinse copiously with DI water.
<b>Comments</b>	TMAH concentration of 2.38%. Normality of 0.261 N. Login to tool <i>Litho Wet Deck #1 - TMAH</i> or <i>Litho Wet Deck #2 - TMAH</i> when using. <b>Wear PPE when handling: chemical-resistant gloves, acid apron, face shield.</b>
<b>Status</b>	<b>STOCKED</b>



## Check First

Please contact a nanoFAB staff member for uses not listed above.